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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/574,863	04/06/2006	Yuichiro Sasaki	061282-0234	5536
	7590 10/04/201 `WILL & EMERY LL	EXAMINER		
600 13TH STREET, NW			FOURSON III, GEORGE R	
WASHINGTON, DC 20005-3096			ART UNIT	PAPER NUMBER
			2823	
			MAIL DATE	DELIVERY MODE
			10/04/2010	PAPER

Please find below and/or attached an Office communication concerning this application or proceeding.

The time period for reply, if any, is set in the attached communication.

	Application No.	Applicant(s)			
	10/574,863	SASAKI ET AL.			
Office Action Summary	Examiner	Art Unit			
	George Fourson	2823			
The MAILING DATE of this communication app Period for Reply	pears on the cover sheet with the c	orrespondence address			
A SHORTENED STATUTORY PERIOD FOR REPLY WHICHEVER IS LONGER, FROM THE MAILING DOWN THE METERS THE	ATE OF THIS COMMUNICATION 36(a). In no event, however, may a reply be tim will apply and will expire SIX (6) MONTHS from , cause the application to become ABANDONEI	lely filed the mailing date of this communication. (35 U.S.C. § 133).			
Status					
Responsive to communication(s) filed on <u>03 M</u> This action is FINAL . 2b) ☐ This Since this application is in condition for alloward closed in accordance with the practice under E	action is non-final.	secution as to the merits is			
Disposition of Claims					
4) Claim(s) 31,33,34,36,37,40-48,50 and 51 is/ar 4a) Of the above claim(s) 49 is/are withdrawn f 5) Claim(s) is/are allowed. 6) Claim(s) 31,33,34,36,37,40-48,50 and 51 is/ar 7) Claim(s) is/are objected to. 8) Claim(s) are subject to restriction and/o Application Papers 9) The specification is objected to by the Examine 10) The drawing(s) filed on is/are: a) acc Applicant may not request that any objection to the Replacement drawing sheet(s) including the correct	rom consideration. e rejected. r election requirement. er. epted or b) objected to by the Edrawing(s) be held in abeyance. See	e 37 CFR 1.85(a).			
11)☐ The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.					
Priority under 35 U.S.C. § 119					
 12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f). a) All b) Some * c) None of: 1. Certified copies of the priority documents have been received. 2. Certified copies of the priority documents have been received in Application No 3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). * See the attached detailed Office action for a list of the certified copies not received. 					
Attachment(s) 1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO/SB/08) Paper No(s)/Mail Date 6/30/2010,9/28/2010.	4) Interview Summary Paper No(s)/Mail Da 5) Notice of Informal P 6) Other:	ite			

A request for continued examination under 37 CFR 1.114, including the fee set forth in 37 CFR 1.17(e), was filed in this application after final rejection. Since this application is eligible for continued examination under 37 CFR 1.114, and the fee set forth in 37 CFR 1.17(e) has been timely paid, the finality of the previous Office action has been withdrawn pursuant to 37 CFR 1.114. Applicant's submission filed on 9/28/2010 has been entered.

Claim 33 is objected to because of the following informalities: In claim 33, "mainly" should be replaced with language more descriptive of the quantity intended because the term "mainly" is subjective. The claims are treated for the purposes of the instant office action to require greater than 50 atomic percent He. Appropriate correction is required.

The text of those sections of Title 35, U.S. Code not included in this action can be found in a prior Office action.

Claims 31,33,34,36,37,40,41,43-46,49,50 and 51 rejected under 35 U.S.C. 103(a) as being unpatentable over Maydan et al 2004/0166612 in view of Zhang et al 2005/0196961 and Downey et al 2004/0235281.

Maydan et al '612 discloses plasma doping an SOI structure [0263] including coimplantation with helium [0293] wherein amorphization of the wafer surface occurs [0265]. The doping is followed by RTA which includes lamp heating or laser annealing [0322]. The claims do not require sequential amorphization and doping. See figures 3 and 4 which show the results of plasma doping wherein the plasma containing the dopant is diluted with helium.

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The reference discloses, as an alternative to co-implantation, preamorphization using Xe or Ar prior to plasma doping [0036] the reference does not disclose a plasma consisting of He for this purpose or a plasma having more that 50 atomic percent He.

Zhang et al 2005/0196961 discloses amorphization using He, Ar or Xe plasma [0019] of a single crystalline Si substrate.

It would have been obvious to one of ordinary skill in the art to combine the teachings of Maydan '612 with those of Zhang et al 2005/0196961 to enable performing the disclosed amorphization step of Maydan '612 according to the teachings of Yang because in such a process the method of Zhang et al 2005/0196961 would be used according to it's disclosed intended purpose and would therefor have reasonably been expected by one of ordinary skill in the art to yield the predictable results of forming the disclosed amorphized region of Maydan '612.

Maydan '612 does not disclose use of Xe lamp in the annealing step or provide guidance with respect to output of the lamp used for annealing with respect to wavelength.

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Downey et al '281 discloses plasma doping of boron [0017] with preamorphization [0032] followed by activation annealing using Xe lamp having a substantial portion of it's output in the 200-1100 nm range. The reference discloses that the wavelength region desired may be chosen by use of an optical filter, use of a different optical source or multiple optical sources [0040-0041]. The reference exemplifies use of an optical source having a range of 300-800 nm [0040]. The reference discloses wavelength range used to be a result effective variable by stating that "different illumination wavelengths can provide different junction-forming performance results" [0066-0067]. There is overlap between the recited range and that disclosed by Downey et al (MPEP 2144.05). Further, one of ordinary skill in the art would have been led to the recited range in view of the guidance provided by Downey et al to obtain desired junction-forming performance results.

It would have been obvious to one of ordinary skill in the art to combine the teachings of Maydan et al '612 and Downey et al to enable performing the disclosed lamp annealing step of Maydan et al '612 according to the teachings of Downey et al because in such a process the method of Downey et al would be used according to it's disclosed intended purpose and would therefor have reasonably been expected by one of ordinary skill in the art to yield the predictable results of performing the disclosed lamp annealing step of Maydan et al. The resulting semiconductor would have the recited properties because the same materials are treated as in the instant invention.

and further in view of the following arguments.

Claims 42,47 and 48 are rejected under 35 U.S.C. 103(a) as being unpatentable over Maydan '612 as applied to claims 31,33,34,36,37,40,41,43-46,50 and 51 above,

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The examiner takes official notice that use of silicon substrates having a (100) crystal orientation, strained Si substrates and glass substrates as SOI structures as recited was known prior to applicant's invention.

It would have been obvious to one of ordinary skill in the art to combine the known processes according to their known intended purposes with the process of Maydan '612 to enable providing the disclosed SOI substrate of Maydan '612 because in the process of the combination the known process would be employed according to their known intended purposes and would therefor reasonably have been expected to provide the predictable results of the disclosed substrate formation step of Maydan '612.

Applicant's arguments regarding Yang are moot in view of the new grounds of rejection above.

Applicant appears to argue that unexpected results are obtained using a He plasma in combination with light having the recited wavelengths. However, applicant has merely recognized results that flow from the process made obvious in view of the references relied on above. The absorption characteristics depicted would be obtained by following the teachings of the references relied on because they are a property of the

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resulting material of the processes made obvious in view of the references relied on above.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to George Fourson whose telephone number is (571)272-1860272-1860. The examiner can normally be reached on Monday through Friday.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Matthew Smith, can be reached on (571) 272-1907. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

/George Fourson/ Primary Examiner, Art Unit 2823

GFourson October 1, 2010